

**AMENDMENT OF THE CLAIMS**

1. (Currently Amended) A fabrication method for a color filter panel of a display device, comprising:

forming a black matrix layer having a first opening on a substrate;

forming a color filter layer on the substrate;

forming an organic layer on the color filter layer and in the first opening;

and

forming a spacer by back-exposing the organic layer to a light through the first opening using the black matrix and the color filter layer as a photomask.

2. (Currently Amended) ~~The method of claim 1, further comprising:~~

A fabrication method for a color filter panel of a display device,  
comprising:

forming a black matrix layer having a first opening on a substrate;

forming a color filter layer on the substrate;

forming an organic layer on the color filter layer and in the first opening;

~~forming a spacer by back-exposing the organic layer through the first opening; and~~

forming a second opening on the first opening and between parts of the color filter layer, wherein the spacer is formed by back-exposing the organic layer through the first and second openings.

3. (Original) The method of claim 2, wherein a size of the second opening is equal to or greater than a size of the first opening.

4. (Original) The method of claim 1, further comprising:  
forming an overcoat layer on the color filter layer; and  
forming an alignment layer on the spacer.

5. (Original) The method of claim 1, further comprising:  
forming a common electrode on the color filter layer; and  
forming an alignment layer on the common electrode and the spacer.

6. (Original) The method of claim 1, wherein the step of forming the spacer comprises:

back exposing the organic layer through the first opening; and  
developing the exposed organic layer.

7. (Currently Amended) ~~The method of claim 2;~~

~~A fabrication method for a color filter panel of a display device,~~

~~comprising:~~

~~forming a black matrix layer having a first opening on a substrate;~~

~~forming a color filter layer on the substrate;~~

~~forming an organic layer on the color filter layer and in the first opening;~~

~~and~~

~~forming a spacer by back-exposing the organic layer through the first~~

~~opening; and~~

wherein in the step of forming the color filter layer, the color filter layer includes an ultraviolet ray absorbent material.

8. (Currently Amended) ~~The method of claim 1;~~

~~A fabrication method for a color filter panel of a display device,~~

~~comprising:~~

~~forming a black matrix layer having a first opening on a substrate;~~

~~forming a color filter layer on the substrate;~~

~~forming an organic layer on the color filter layer and in the first opening;~~

~~and~~

~~forming a spacer by back-exposing the organic layer through the first opening; and~~

wherein in the step of forming the spacer, the back-exposing is performed by using a glass filter.

9. (Original) The method of claim 8, wherein the glass filter blocks a wavelength of at least 360 nm.

10-27. (Canceled)

28. (Previously Presented) The method of claim 5, wherein the spacer is formed directly on the common electrode.

29. (Previously Presented) The method of claim 6, wherein the spacer is formed directly on a common electrode.